Abstract

The present invention provides a visible lightsensitive composition which is highly sensitive to a visible
light and is useful as an electronic circuit forming
material, a lithographic printing material, etc., said
visible light-sensitive composition comprising (a) a polymer
comprising a repeating unit represented by general formula
(I):

$$\bigcap_{\mathbf{R}^3} \bigcap_{\mathbf{R}^2} \bigcap_{\mathbf{R}^1} \bigcap_{\mathbf{R}^1} \bigcap_{\mathbf{R}^3} \bigcap_{\mathbf{R}^2} \bigcap_{\mathbf{R}^2} \bigcap_{\mathbf{R}^3} \bigcap_{\mathbf{R}^3$$

wherein R¹, R², and R³ are the same or different and each represents substituted or unsubstituted alkyl, substituted or unsubstituted aryl, or substituted or unsubstituted aralkyl, or alternatively R¹ and R² form cycloalkyl together with the adjacent carbon atom, and R⁴ represents lower alkyl, (b) a compound that generates an acid by visible light irradiation and (c) a sensitizing dye.